Adsorption of Fluorine on single layer MoS$_2$: a first principles study$^1$ CONRAD TROHA, DUY LE, TALAT S. RAHMAN, Department of Physics, University of Central Florida — One of the effective methods for tuning properties of single layer MoS$_2$ is to impose interactions with adsorbates. Using density functional theory, with the optB88-vdW exchange correlation functional, we have studied the adsorption of fluorine atoms on a single layer MoS$_2$. We find that fluorine atoms prefer to adsorb on top of sulfur atoms in (2 × 2), (3 × 3), and (4 × 4) overlayer structures and that at 1/9 ML or smaller coverage, the interactions between fluorine atoms are small and can be ignored. The band structures of the considered overlayer structures suggest that the adsorption of fluorine atoms introduces defect state inside the band-gap of MoS$_2$. This state disperses near the Fermi level in the (2 × 2) overlayer structure and is dispersionless in the (3 × 3) or larger overlayer structures.

$^1$Work supported in part by DOE Grant DE-FG02-07ER15842

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Date submitted: 14 Nov 2014